

THE COMMISSIONER OF PATENTS AND TRADEMARKS
Washington, D.C. 20231

Docket TSMC98-262

J4902 U.S. PTO
09/325951
06/04/99

Sir:

Transmitted herewith for filing is the Patent Application of:

Inventor: MIN-HSIUNG CHIANG, JIN-YUAN LEE AND JENN MING HUANG

For: METHOD FOR FORMING HIGH PURITY SILICON OXIDE FIELD OXIDE ISOLATION REGION

JC586 U.S. PTO



Enclosed are:

06/04/99

1 sheets of drawing(s) - formal.

An assignment of the invention to Taiwan Semiconductor Manufacturing Company

An associate power of attorney

The filing fee has been calculated as shown below:

	(Col. 1)	(Col. 2)	OTHER THAN A SMALL ENTITY
FOR:	NO. FILED	NO. EXTRA	RATE
BASIC FEE			\$ 760.
TOTAL CLAIMS	10 -20=	0	x 18 = \$ 0.
INDEP CLAIMS	2 -3=	0	x 78 = \$ 0.
MULTIPLE DEPENDENT CLAIM PRESENTED		+ 260 =	
			SUB TOTAL \$ 760.
			ASSIGNMENT \$40.
			TOTAL \$ 800.

Please charge my Deposit Account No. 19-0033 in the amount of \$ 800. A duplicate copy of this sheet is enclosed.

The Commissioner is hereby authorized to charge payment of the following fees associated with this communication or credit any overpayment to Deposit Account No. 19-0033. A duplicate copy of this sheet is enclosed.

Any additional filing fees required under 37 CFR §1.16.

Any patent application processing fees under 37 CFR §1.17.

Respectfully submitted,
Stephen B. Ackerman
STEPHEN B. ACKERMAN, REG. NO. 37,761